



# IEEE SW Test Workshop

## Semiconductor Wafer Test Workshop

June 8 - 11, 2014 | San Diego, California

# International Technology Roadmap for Semiconductors

**ADVANTEST.**



**FORMFACTOR INC.**

Dave Armstrong – Advantest

Ira Feldman – Feldman Engineering

Marc Loranger - FormFactor

# Overview

- Who are we?
- Why a roadmap?
- What is the purpose?
- Example Trends
- How can you help?
- Summary

# ITRS Team

- **Large ITRS Team**

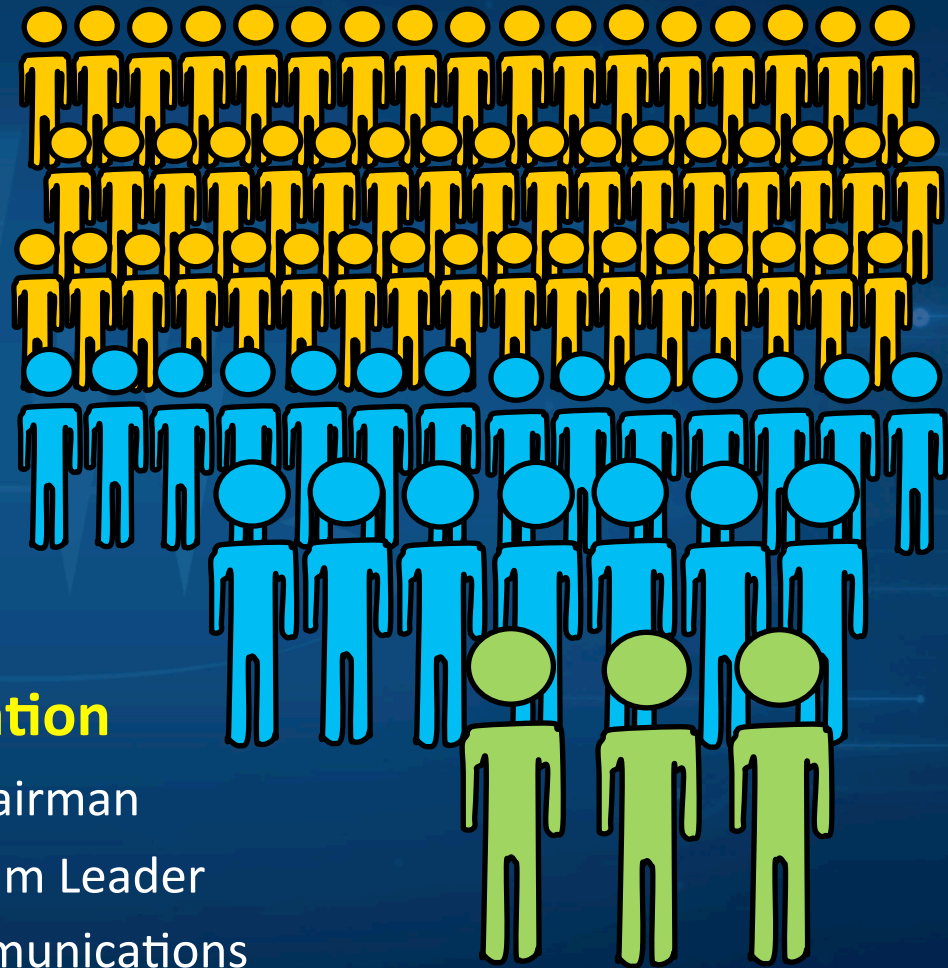
- More than a 1,000 professionals
- Over 100 companies
- 16 Working Groups

- **Test Working Group**

- More than 70 professionals
- More than 45 companies

- **Three authors of this presentation**

- Dave (Advantest) – Test TWG Chairman
- Marc (FormFactor) - Probing Team Leader
- Ira (Feldman Engineering) - Communications



# Why a Roadmap?

- The ITRS is generated each year to report on the technological fundamentals of our industry.
- In addition, by extrapolating on the trends inherent in today's semiconductor technology we identify disconnects and discuss possible approach to overcome these challenges.
- Through this effort we all can get a better sense of the path of least resistance and align our plans and standards in a fashion which is most likely to succeed.

# What Is and What Isn't the ITRS

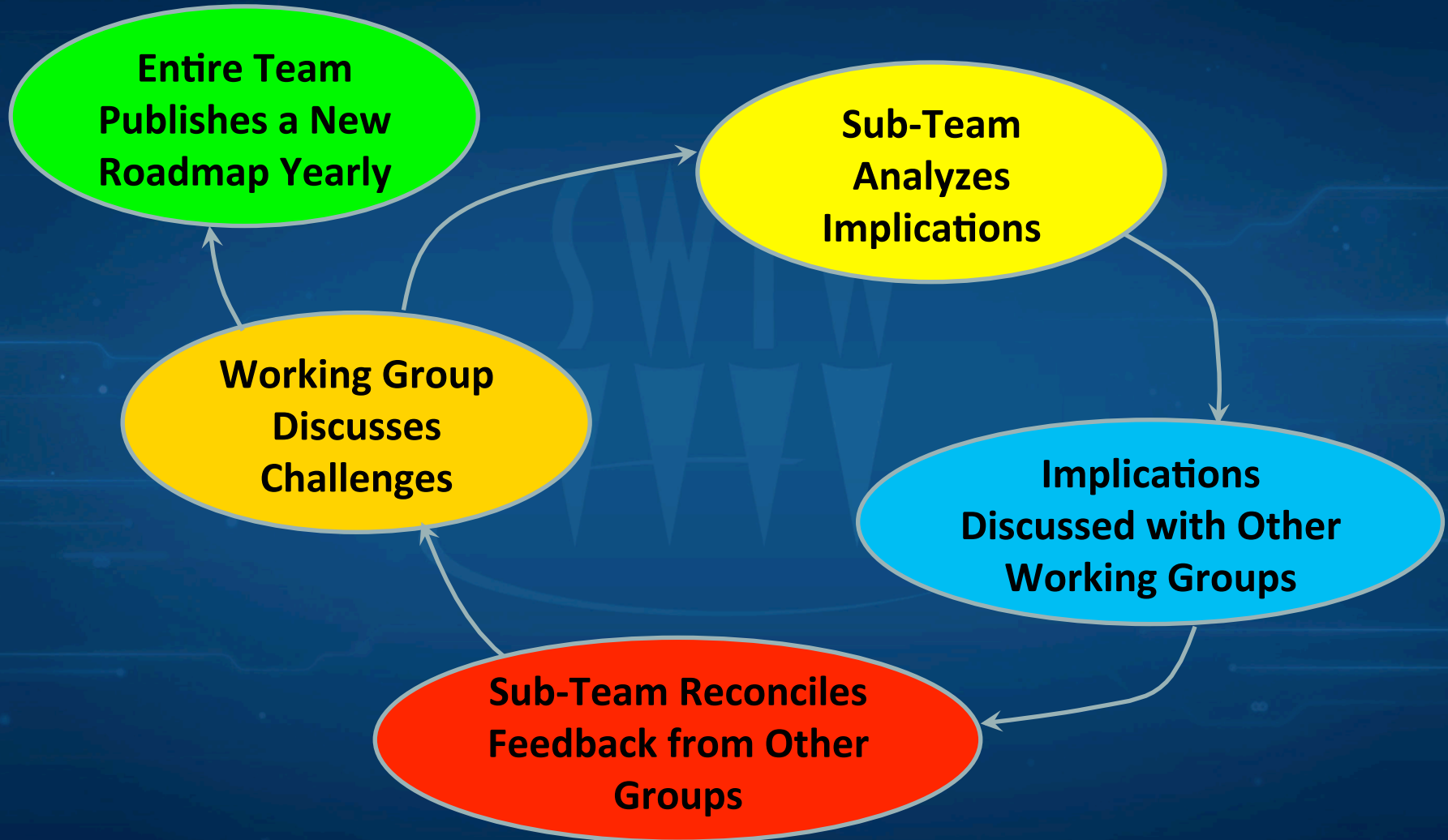
## What Is the ITRS

- The combined expert opinion by this team.
- The results of many different technology models.
- A “best guess” of where the industry is heading for the next 15 years.
- A highlighting of disconnects and significant challenges.

## What Isn't the ITRS

- It doesn't implement or define Moore's Law – it just tries to predict how things will likely trend.
- A commitment from the involved companies to do what is reported.
- Specific solutions or prescriptive.

# ITRS Process





# Test Complexity Drivers

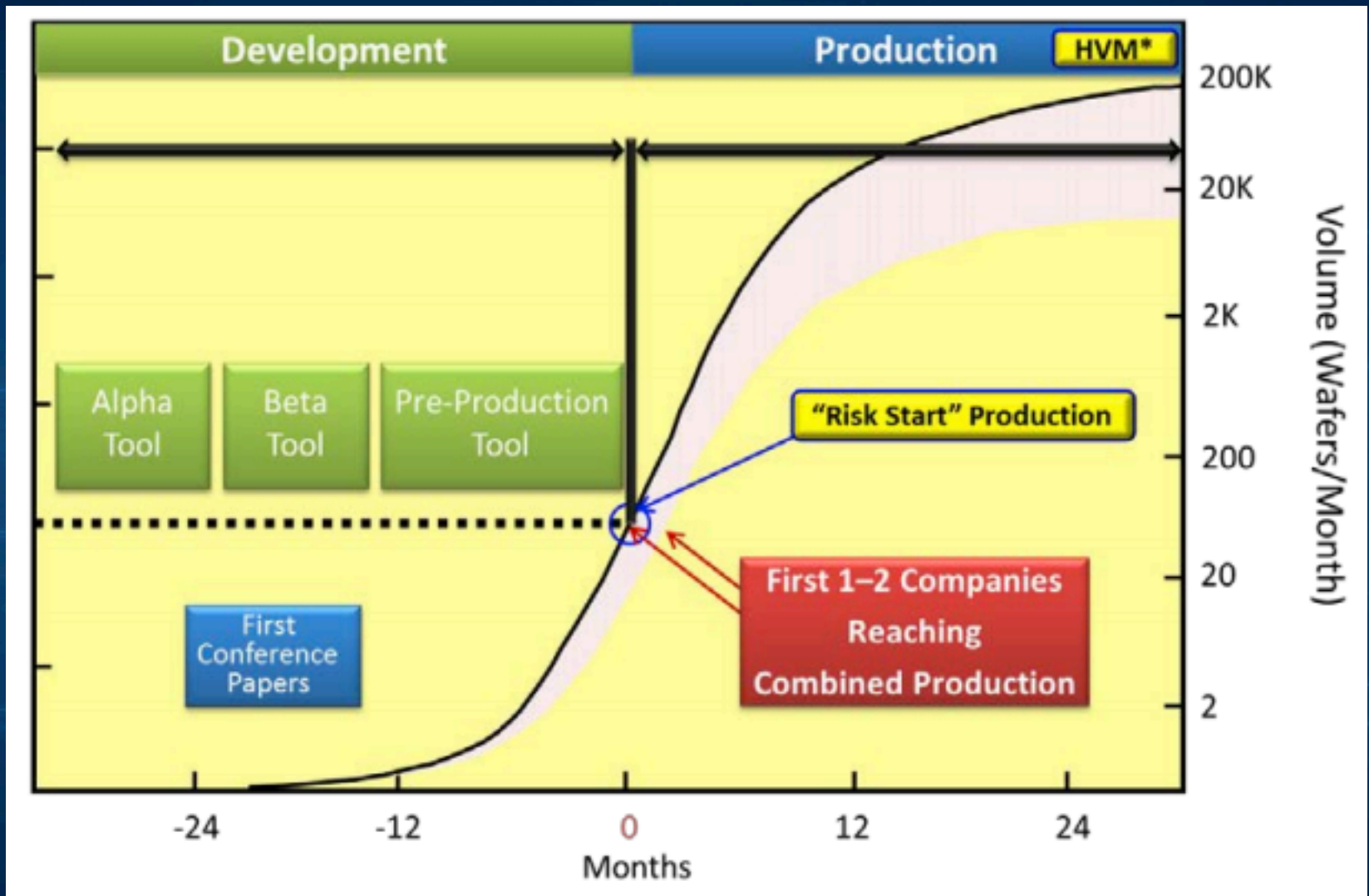
- **Device trends**

- Increasing device interface bandwidth
- Increasing device integration (SoC, SiP, MCP, 3D packaging)
  - Homogenous & heterogeneous dies → functional disaggregation
- Integration of emerging and non-digital CMOS technologies
- Complex package electrical and mechanical characteristics
- Device characteristics beyond one sided stimulus/response model
- 3 Dimensional silicon - multi-die and Multi-layer
- Integration of non-electrical devices (optical, MEMS, etc.)
- Fault Tolerant Architectures and Protocols

- **Industry trends**

- 450 mm wafer transition

# Date = When in Production



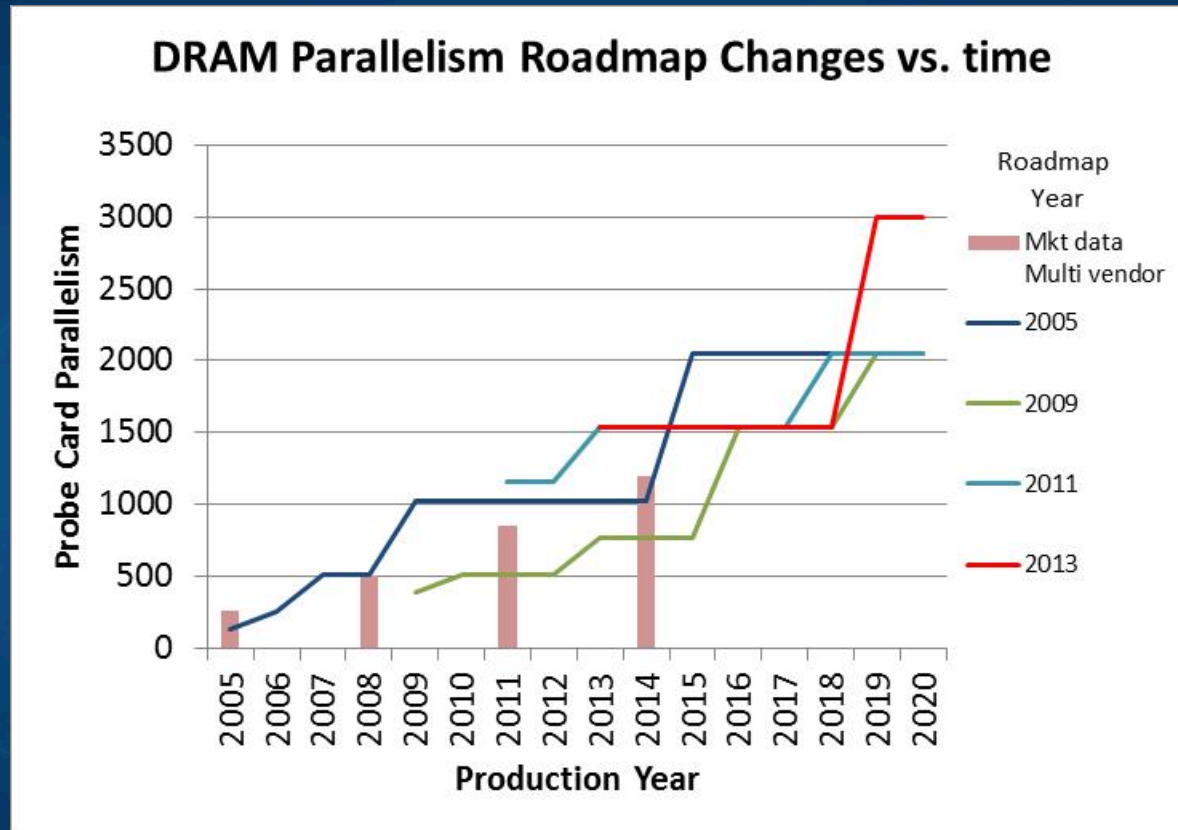
ITRS 2013 Overview: Figure 1a A Typical Technology Production "Ramp" Curve (within an established wafer generation)



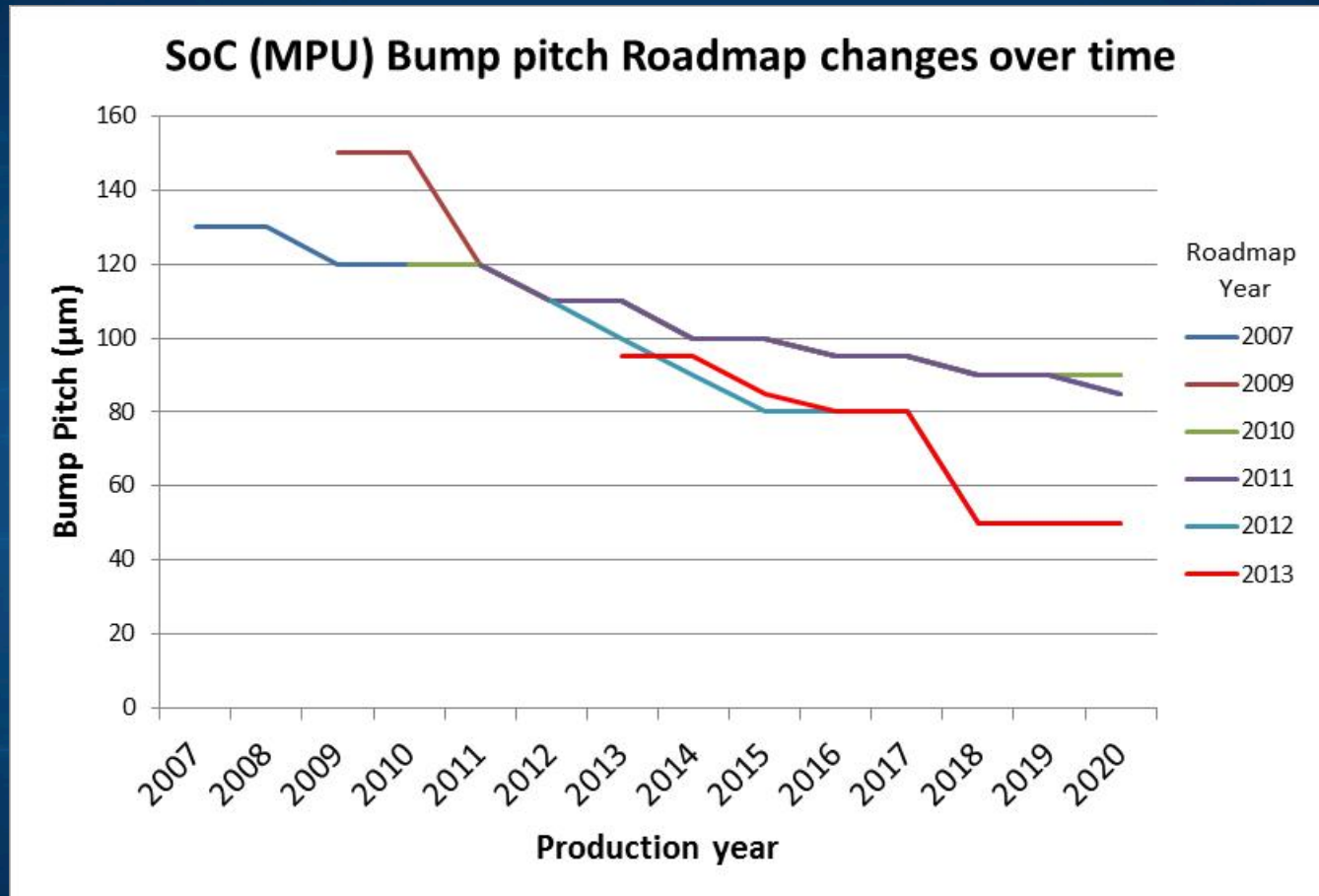
# Wafer Probe Requirements

Parameter	MPU & ASIC	DRAM	NAND	RF & AMS	LCD Drivers	CIS
Wirebond – inline pad pitch	X	X	X	X	X	X
Wirebond – stagger pad pitch	X			X	X	
Bump – array pitch	X			X		
I/O Pad Size	X	X	X	X		X
Wafer Test Frequency	X	X	X			X
High Speed I/O Frequency	X				X	X
Wirebond - Probe Tip Diameter	X	X	X	X	X	X
Bump – Probe Tip Diameter	X			X		
Probe Force	X	X	X		X	X
Probe (Active) Area	X	X	X	X	X	X
# of Probes per Touchdown	X	X	X	X	X	X
Maximum Current / Probe		X	X	X	X	X
Maximum Resistance		X	X		X	

# Parallelism Trend



# SoC (MPU) Bump Pitch Trend



- Technology shift in 2012

# Prober accuracy vs. Pad size

	2013		2014		2015		2016		2017		2018	
DRAM												
Wirebond - inline pad pitch	55		50		45		40		40		40	
I/O Pad Size ( $\mu\text{m}$ )	X	Y	X	Y	X	Y	X	Y	X	Y	X	Y
Wirebond	45	45	40	45	40	40	35	40	35	40	35	40
Prober												
XY Accuracy(Probe to Pad) [ $\mu\text{m}$ ]	2.0		2.0		2.0		2.0		2.0		2.0	
Z Accuracy(Probe to Pad) [ $\mu\text{m}$ ]	5.0		5.0		5.0		5.0		5.0		5.0	
Chuck Planarity [ $\pm\mu\text{m}$ ]	7.5		7.5		7.5		7.5		7.5		7.5	

- Prober roadmap is not tracking with decreasing pad sizes
- An especially difficult issue for Full Wafer Contactor probe cards

# Next Challenges for Probe Cards

- Decreasing pad / bump sizes and pitch
- Increasing parallelism SoC and Memory
- Increased use of die for MCP, 2.5D and 3D integration will drive more wafer sort
- 2 sided probing
- Testing stacked devices (e.g. HBM)
- MEMS and sensor sort test
- Cost of test as a driver

# Opportunities for Involvement!

- **Download ITRS data at:**

<http://www.itrs.net/Links/2013ITRS/Home2013.htm>

- **Provide feedback on test data at:**

<http://j.mp/ITRSTestSurvey>

- **Sign up:**

[dave.armstrong@advantest.com](mailto:dave.armstrong@advantest.com)



# Summary

- **Great Tool**

- Well accepted independent industry wide reference

- **Challenges**

- Requires broad-based inputs
- Track potential disruptive technology

- **Help Us**

- Get Involved!